ISTITUTO NAZIONALE di FISICA NUCLEARE UNIVERSITY of PADUA In the framework of the MASTER In "Surface Treatments for Industrial Applications" and the TESLA Technology Collaboration

The International Workshop on: THIN FILMS AND NEW IDEAS FOR PUSHING THE LIMITS OF RF SUPERCONDUCTIVITY

> October 9 – 12, 2006 Legnaro National Laboratories (Padua) ITALY



Bejing 2004: the Choice of Cold Technology Evaluation Matrix

Matrix parameters which turned out to be more important:

Scientific issues Technical issues Physics operation issues Schedule issues Social impact of ILC

It was agreed that cost of either machine could not be reliably assessed. <u>Cost was removed from the matrix</u>.

Giorgio Bellettini

Beijing 2004 - International Conference on High Energy Physics



International Technology Recommendation Panel of the International Committee for Future Accelerators (ICFA)

Front line from left to right: Akira Masaike, George Kalmus, Volker Soergel, Barry Barish, Giorgio Bellettini, Hirotaka Sugawara,Paul Grannis Back line from left to right: Gyung-Su Lee, Jean-Eude Augustin, David Plane, Jonathan Bagger, Norbert Holtkamp, Katsunobu Oide

"... On the basis of that assessment, we recommend that the linear collider be based on "...We based our decision on a set of criteria that superconducting rf technology additestad setematic, technicogy attastee dule, operability is sives for head by echapld goods for the former of the street of the second stand the second stand the second stand s wodlad impacts on the field and beyond ... " **Each offers its own advantages**, and each represents Then at SCRE Cornell 2005 many years of R&D by teams of extremely talented and de"dibited site and in a length elers. At this stage it would be too costly and the consuming to develop both IS MANDATORY!" technologies toward construction...."

Barry Barish

Workshop Aim

The present superconducting RF accelerator technology is based on solid Nb. Thin film technology offers considerable savings in fabrication costs and what is even more important it opens the way to use alternative superconducting material with enhanced intrinsic properties such as critical temperature and critical field. Intensive and coordinated R&D effort is of decisive importance to explore the realization of this promise and to make the benefits available to the next generation of SC accelerators. The aim of this workshop is to bundle the expertise from industry, research laboratories and accelerator technology in order to launch a new initiative in thin film and innovative related technology for superconducting RF accelerator application. The immediate infusion of industrial expertise and specialists from cross-disciplinary fields, as for instance superconductivity, plasma physics, material science. **nanotechnology and rf engineering**, is of crucial importance

- Superconductivity
- Plasma Physics,
- Material Science
- Nanotechnology
- Rf Engineering





68.817

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Surface Analysis Techniques

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- 47 talks over 3 ¹/₂ days
- 68 participants
- International workshop \rightarrow 3 regions represented

INFN / CNR / Univ. - DESY / Max Plank Inst. / Nurnberg Univ.

- CNRS / CEA - CERN - Andrzej Soltan Inst. - Tel Aviv Univ.

JLab – Los Alamos - Argonne - Fermi Lab - Cornell / California / Florida Univ. - SLAC

KEK - China Institute of Atomic Energy

Workshop Items

- Niobium Coatings
- Characterization Techniques
- SRF Theory
- A15 Materials
- Magnesium Diboride
- Power Couplers and Subsidiaries
- Advanced Cavity Cleaning
- Arc Deposition

Niobium thin films

State-of-the-art at 1500 MHz – 1.7 K – single cell



28 MV/m reached in a large LEP cryostat (He evaporation at large power)

Defects in Cu substrate



Electropolished copper surface

- average roughness: 0.02 μm
- A few defects still appearing

Cross section of a copper cavity

- Defects are present inside !
- Not an artifact of the preparation

Surface resistance at zero RF field



Squares: coatings on oxide-free copper Circles: coatings on oxidized copper





Standard 1.5 GHz Nb/Cu cavity

Variation of target-substrate incidence angle





Biased Magnetron Sputtering: the construction



Biased Magnetron Sputtering: RRR results



The grid still doesn't affect much the equator part



UHV arc systems with a linear cathode





Scheme of the UHV system with a linear (cylindrical) arc and the first linear-arc facility constructed at IPJ in Swierk, Poland, in 2005.

Intern. Workshop, Legnaro, 2006

M.J. Sadowski et al.

Preliminary test for cavity coating

The first single-cavity taken of the real accelerator unit, after its preparation, has been coated without micro-droplet filtering.



The coated single-cell has been cut along its symmetry axis in order to perform an analysis of the inner surfaces.



New cylindrical filters for elimination of micro-droplets





A cylindrical magnetic filter consisting of current-carrying tubes (left) and the distribution of magnetic field lines in its cross-section (right).

Intern. Workshop, Legnaro, 2006

M.J. Sadowski et al.

Other Arc Modes proposed by Ray Boxman

- Hot Anode Vacuum Arc
 - Crucible anode
- Hot Refractory Anode Vacuum







Sputtering:

The film Microstructure is affected by the non-zero cathode - substrate angle

Cathodic Arc:

The film Morphology suffers of the presence of microparticles

But there is something without the limits of both these techniques



Characterization

Techniques



Elastic modulus and ISE

Biased MS E = 88,95 GPa



unbiased MS E = 54,33 GPa



INFN Workshop, 10-2006

Bemporad et al.: High resolution morphological and mechanical characterization of niobium films obtained by MS and Bias-MS PVD



INFN Workshop, 10-2006

Bemporad et al.: High resolution morphological and mechanical characterization of niobium films obtained by MS and Bias-MS PVD



Hardness comparison



MgB2 thin film on STOCBS 33-1-5 ZFC T=16K increasing H from 0 to



#1 H=8mT



#5 H=20mT



elije) nadacijeji ja



#9 H=40mT



#11 H=60mT

#13 H=80mT

MORPHOLOGY OF NIOBIUM FILMS SPUTTERED AT DIFFERENT TARGET – SUBSTRATE ANGLE D. Tonini, C. Greggio, G. Keppel, F. Laviano, M. Musiani, G. Torzo, V. Palmieri





Substrate at 45 degrees from the target

Magnetic sensors & applications

Magnetic field (Tesla)



M. Valentino

Buffered Chemical polishing of Niobium

BCP 1:1:1 to BCP 1:1:2 increasing the H_3PO_4 percentage the magnetic signal Intensity increase



M. Valentino



The IMD technique

A. Andreone

Input signal made up of two signals of equal magnitude but different frequencies:

 $V_{in} = V_1 \cos(2\pi f_1 t + a_1) + V_2 \cos(2\pi f_2 t + a_2)$





CaC₆: a graphite intercalated superconductor

$$T_{\rm C} = 11.2 \, {\rm K}$$



Both superfluid density and microwave losses give evidence of conventional, weak-coupled, superconductivity $(2\Delta/K_BT_C \sim 3.6)$



G. Lamura al, Phys. Rev. Lett. 96, 107008 (2006); G. Cifariello et al., M²S 2006

SRF Theory

Electrodynamics of Superconductors exposed to high frequency fields

- Superconductivity
- Radio frequency response of ideal superconductors
 - two-fluid model, microscopic theory
- Abrikosov vortices
- Dissipation by moving vortices
- Penetration of vortices

"Thin films applied to Superconducting RF:Pushing the limits of RF Superconductivity" Legnaro National Laboratories of the ISTITUTO NAZIONALE DI FISICA NUCLEARE in Legnaro (Padova) ITALY, October 9-12, 2006



5. Ideal diamagnet, corner with angle α :

Near corner of angle α the magnetic field diverges as H ~ 1/ r^{β}, $\beta = (\pi - \alpha)/(2\pi - \alpha)$







in form of a vortex lattice



Y / N = theory in **agreement** / **contradiction** with experimental observation N+ / = undisputable disagreement with experiment

International Workshop on Thin Films - Legnaro - October 2006



Best 9-cell cavity result (after electro-polishing) (Courtesy D. Proch)



This formula has done a lot of damage to our community for the understanding of the Q-Slope This relation goes back to first principles

 $\Delta = \Delta_0 - p_f v_s$

It means to take into account the supercurrent!

If for Superconducting Magnets the fundamental and indipendent parameters are 3: T_c , H_c and J_c ,

why for Superconducting cavities, JC disappeared? Is 40 MV/m (1600 G) a field not strong enough? In local electrodynamics of superconductivity, $j = j_1 + j_2$

Where J₁ is the Meissner current $j_1 = n_s ev(s_1 - \frac{v_s^2}{v_s^2})$

At small supercurrent

$$\dot{n}_1 = n_s ev$$

but at larger V_s , GL theory foresees a deparing effect by the current

Over V_m the superconducting state become unstable

A15 Materials

High Field Superconductors with

Technological Potential

Material	Structure Classification	Тс (К)	H _{c2} (T) Obs. 4.2K	Jc (A.cm ⁻²) 4.2 K (T)
Nb-Ti	A-2	10.2	12	5 x 10 ⁵ (5 T)
Nb-Zr	A-2	10.8	11	
V ₃ Ga	A-15	15.5	23.6	2 x 10 ⁶ (10T)
V ₃ Si	A-15	17.0	23	
Nb ₃ Sn	A-15	18.3	26	3 x 10 ⁵ (10T)
Nb ₃ AI	A-15	18.9	29.5	10 ⁵ (22T)
Nb ₃ (AI,B,Be)	A-15	20.0		3 x 10 ⁴ (8T)
Nb ₃ Ga	A-15	20.3	33	
Nb ₃ (AI,Ge)	A-15	20.5	41	1 x 10 ⁴ (12T)
Nb ₃ Ge	A-15	23.2	37	
NbCN	B-1	17.8	12	1 x 10 ³ (7T)
V ₂ (Hf,Zr)Lave	C-15	10.1	23	3 x 10 ⁵ (6T)
PbMo ₆ S ₈	C-15	14.0	65	

Sn content: Lattice parameter

a increases with Sn content (as does T_c (below))

RF Superconductivity Workshop – Padua, Italy

S.Deambrosis et al

Method: "1 step" process

Reactive sputtered V₃Si films

Y. Zhang, V. Palmieri, W. Venturini, R. Preciso, Legnaro National Laboratory - INFN, Italy

Surface of two annealed samples under SEM: Grain size, (a) $0.2\mu m$, (b) $0.5\mu m$

Thermal diffusion of V₃Si films

Y. Zhang, V. Palmieri, W. Venturini, F. Stivanello, R. Preciso, Legnaro National Laboratory, ITALY

Literature

Very Clean HPCVD MgB₂ Films: RRR > 80

Degradation of HPCVD MgB₂ Films in Water

— Film properties degrade with exposure to air/moisture: resistance goes up, T_c goes down

— Experiments show that MgB_2 degrades quickly in water, and is sensitive to temperature.

Advanced Cleaning

Case 3

A woman etching computer chips developed a pin-hole in her glove during the four hours that she was working in a dip tank with 5% hydrogen fluoride. She went to a doctor's office where **a non-specific burn ointment was applied** (no calcium gluconate was applied). She continued to have pain during the next four days. At that time she had severe pain under the finger nail and the subungual tissues were black. There was mild erythema around the proximal cuticle. Upon removal of the finger nail at a burn treatment center where she was referred, exposed and necrotic bone was identified. The distal phalanx was demineralized and the patient required distal amputation of the finger (Edelman, 1986).

Hydrofluoric acid (HF) differs from other acids because the fluoride ion readily penetrates the skin, causing destruction of deep tissue layers, including bone.

Pain associated with exposure to solutions of HF (1-50%) may be delayed for 1-24 hours. If HF is not rapidly neutralized and the fluoride ion bound, tissue destruction may continue for days and result in limb loss or death.

... Do you really want I continue with case 4?

On the basis of Abbott Patent, We succeeded in electropolishing Nb!

Choline Chloride Drink

The brain has a voracious appetite for choline. There are two main reasons for the brain's huge need for this nutrient: Choline is required for synthesis of the key neurotransmitter acetylcholine, and it is used for the building and maintenance of brain cell membranes. Acetylcholine is vital for thought, memory and sleep, and is also involved in the control of movements

Dosage and Use

Take 1 to 3 teaspoons daily. It is best mixed with approximately 2 oz. of juice per teaspoon.

6 GHz cavity

TM010 plasma at a power of 50 W

Cavity

JUST AN EXAMPLE of how we also should work:

Xiaoxing Xi group (Physics and Materials Sci & Eng); Ke Chen, Derek Wilke, Yi Cui, Chenggang Zhuang (Beijing), Arsen Soukiassian, Valeria Ferrando (Genoa); Pasquale Orgiani (Naples); Alexej Pogrebnyakov, Dmitri Tenne, Xianghui Zeng, Baoting Liu: CVD growth, electrical characterization, junctions

Joan Redwing Group (Materials Sci & Eng): HPCVD growth, modeling

Qi Li Group (Physics): Junctions, transport and magnetic measurements

Darrell Schlom Group (Materials Sci & Eng): structural analysis

Zi-Kui Liu Group (Materials Sci & Eng): Thermodynamics

Xiaoqing Pan Group (U. Michigan): Cross-Section TEM

John Spence Group (ASU): TEM

N. Klein Group (Jülich): Microwave measurement

A. Findikoglu (LANL): Microwave measurement

Qiang Li Group (Brookhaven National Lab): Magneto-optic measurement

Tom Johansen Group (U Oslo): Magneto-optic measurement

Qing-Rong Feng Group (Peking University): SiC fiber

Chang-Beom Eom Group (U Wisconsin): Structural analysis

J. B. Betts and C. H. Mielke (LANL): High field measurement

